WHAT IS CLAIMED IS:

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- 1. 1 A method of maintaining printed circuit board manufacturing equipment 2 comprising contacting a component of the equipment with a composition including an oxidant. 3 2. 1 The method of claim 1, wherein the composition is an aqueous solution. 3. The method of claim 1, wherein the oxidant includes a peroxide. 1 4. 1 The method of claim 1, wherein the composition further comprises a pH modifier. 2 5. 1 The method of claim 4, wherein the pH modifier includes a carbonate salt. 6. The method of claim 4, wherein the pH modifier is an acid. 1 7. The method of claim 4, wherein the pH modifier is a base. 1 The method of claim 4, wherein the pH modifier includes sodium carbonate. 1 8. 9. The method of claim 4, wherein the pH modifier includes acetic acid. 1 10. The method of claim 1, wherein the component includes a residue. 1 The method of claim 10, wherein the residue includes a resist, a soldermask, 11. 1 2 an antifoam agent, or a hard water deposit. 12. The method of claim 10, further comprising oxidizing the residue. 1 13. The method of claim 10, further comprising dispersing the residue. 1 The method of claim 10, further comprising dissolving the residue. 1 14.
 - 16. The method of claim 15, further comprising passing the composition through the nozzle.

The method of claim 1, wherein the component includes a nozzle.

- 1 The method of claim 15, wherein the component includes a second nozzle.
- 1 18. The method of claim 17, further comprising passing the solution through the first nozzle and the second nozzle simultaneously.
- 1 19. The method of claim 1, wherein contacting includes maintaining the composition at a temperature greater than 80 °F.
- 1 20. The method of claim 1, wherein the oxidant includes hydrogen peroxide.
- 1 21. The method of claim 1, wherein the oxidant includes sodium perborate.
- 1 22. The method of claim 1, wherein the oxidant includes an organic peroxide, a peracid, or a hydroperoxide.
- 1 23. The method of claim 1, wherein the solution includes a surfactant that is not oxidized by the oxidant.
- 1 24. The method of claim 1, further comprising removing a waste material from 2 the equipment, the waste material including water, an oxidant, and an oxidized resist.

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- 25. A method of cleaning printed circuit board manufacturing equipment comprising contacting a component of the equipment including a residue with an aqueous composition including an oxidant to oxidize the residue.
- 1 26. The method of claim 25, wherein the residue includes a resist, a soldermask, an antifoam agent, or a hard water deposit.
 - 27. The method of claim 25, further comprising dispersing the residue.
- 1 28. The method of claim 25, further comprising dissolving the residue.
- 1 29. The method of claim 25, wherein the component includes a nozzle.
- 1 30. The method of claim 25, wherein the oxidant includes hydrogen peroxide.

31. 1 The method of claim 25, wherein the aqueous composition includes sodium 2 carbonate. The method of claim 25, wherein the aqueous composition includes acetic 1 32. acid. 2 33. The method of claim 25, wherein the oxidant includes an organic peroxide, a 1 peracid, or a hydroperoxide. 2 34. The method of claim 25, further comprising removing a waste material from 1 the equipment, the waste material including water, an oxidant, and an oxidized resist. 2 35. A method of manufacturing a printed circuit comprising contacting a board 1 including a resist with a composition comprising an oxidant. 2 36. The method of claim 35, further comprising oxidizing the resist. 1 37. The method of claim 35, wherein the resist is overplated. 1 38. The method of claim 35, wherein contacting the board with the composition 1 includes spraying the composition on the board. 2 39. The method of claim 35, wherein contacting the board with the composition 1 includes immersing the board in the composition. 2 The method of claim 35, wherein the composition includes a pH modifier. 40. 1 The method of claim 40, wherein the pH modifier is an acid. 1 41. The method of claim 40, wherein the pH modifier is a base. 42. 1

The method of claim 40, wherein the pH modifier includes sodium carbonate.

The method of claim 40, wherein the pH modifier includes sodium carbonate

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and the oxidant include hydrogen peroxide.

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- 1 45. The method of claim 35, further comprising maintaining the composition at a temperature greater than 80 °F.
- 1 46. The method of claim 35, wherein the oxidant includes hydrogen peroxide.
- 1 47. The method of claim 35, wherein the oxidant includes sodium perborate.
- 1 48. The method of claim 35, wherein the oxidant includes an organic peroxide, a peracid, or a hydroperoxide.
- 1 49. The method of claim 35, further comprising removing a waste material from 2 the equipment, the waste material including water, an oxidant, and an oxidized resist.
- 1 50. A composition for treating a printed circuit board resist comprising an aqueous solution of an oxidant.
- 1 51. The composition of claim 50, further comprising a pH modifier.
- 1 52. The composition of claim 51, wherein the pH modifier is a carbonate salt.
- 1 53. The composition of claim 52, wherein the concentration of the carbonate salt 2 is between 20 grams per liter and 200 grams per liter.
- 1 54. The composition of claim 50, wherein the oxidant includes an organic peroxide, a peracid, or a hydroperoxide.

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- 55. The composition of claim 50, further comprising a surfactant that is not oxidized by the oxidant.
- 1 56. The composition of claim 50, wherein the oxidant is hydrogen peroxide.
- The composition of claim 56, wherein the concentration of hydrogen peroxide is between 2.0% and 10% by volume.
- 1 58. The composition of claim 56, further comprising a pH modifier.
 - 59. The composition of claim 58, wherein the pH modifier is a carbonate salt

1 60. The composition of claim 59, wherein the concentration of hydrogen peroxide 2 is between 2.0% and 10% by volume and the concentration of the carbonate salt is between 3 20 grams per liter and 200 grams per liter.

- 61. The composition of claim 59, wherein the concentration of hydrogen peroxide is between 3% and 6% by volume and the concentration of sodium carbonate is between 40 grams per liter and 100 grams per liter.
- 1 62. A composition for treating a printed circuit board resist comprising an aqueous solution of hydrogen peroxide and acetic acid.

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- 63. The composition of claim 62, wherein the concentration of hydrogen peroxide is between 2.0% and 10% by volume.
- 64. The composition of claim 62, wherein the concentration of acetic acid is between 1% and 10% by volume.
 - 65. The composition of claim 62, wherein the concentration of hydrogen peroxide is between 2.0% and 10% by volume and the concentration of acetic acid is between 1% and 10% by volume.
 - 66. The composition of claim 62, wherein the concentration of hydrogen peroxide is between 3% and 6% by volume and the concentration of acetic acid is between 3% and 6% by volume.
 - 67. A composition for treating a printed circuit board resist consisting essentially of an aqueous solution of an oxidant and a pH modifier.
- 68. A composition for treating a printed circuit board resist consisting essentially of an aqueous solution of hydrogen peroxide and a carbonate salt.